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	Application No.	Applicant(s)	_
	10/616,996	OGASAWARA ET AL.	OGASAWARA ET AL.
Notice of Allowability	Examiner	Art Unit	
	Jennifer M. Dolan	2813	
The MAILING DATE of this communication All claims being allowable, PROSECUTION ON THE ME herewith (or previously mailed), a Notice of Allowance (P'NOTICE OF ALLOWABILITY IS NOT A GRANT OF PA' of the Office or upon petition by the applicant. See 37 CF	RITS IS (OR REMAINS) CLOSED in TOL-85) or other appropriate commu TENT RIGHTS . This application is s	this application. If not included nication will be mailed in due course. THIS	'e
1. This communication is responsive to <u>Amdt. of 2/11</u>	<u>1/05</u> .		
2. The allowed claim(s) is/are <u>1-20</u> .			
3. X The drawings filed on 11 July 2003 are accepted by	by the Examiner.		
 4. Acknowledgment is made of a claim for foreign p a) All b) Some* c) None of the: 1. Certified copies of the priority docume 	nts have been received.	· ·	
2. Certified copies of the priority docume	· ·	· · · · · · · · · · · · · · · · · · ·	
3. Copies of the certified copies of the pr	•	in this national stage application from the	
International Bureau (PCT Rule 17.2(a	a)).		
* Certified copies not received:		,	
Applicant has THREE MONTHS FROM THE "MAILING noted below. Failure to timely comply will result in ABA THIS THREE-MONTH PERIOD IS NOT EXTENDABLE 5. A SUBSTITUTE OATH OR DECLARATION must be a substitute of the complex of the comple	NDONMENT of this application.		
INFORMAL PATENT APPLICATION (PTO-152) w	hich gives reason(s) why the oath or	declaration is deficient.	
6. CORRECTED DRAWINGS (as "replacement sheet	ets") must be submitted.		
(a) ☐ including changes required by the Notice of Di	· · ·	(PTO-948) attached	
1) ☐ hereto or 2) ☐ to Paper No./Mail Dat			
(b) ☐ including changes required by the attached Ex Paper No./Mail Date	caminer's Amendment / Comment or	in the Office action of	
Identifying indicia such as the application number (see a each sheet. Replacement sheet(s) should be labeled as	37 CFR 1.84(c)) should be written on th such in the header according to 37 CFI	e drawings in the front (not the back) of R 1.121(d).	•
 DEPOSIT OF and/or INFORMATION about the attached Examiner's comment regarding REQUIR! 	e deposit of BIOLOGICAL MATE EMENT FOR THE DEPOSIT OF BIO	RIAL must be submitted. Note the LOGICAL MATERIAL.	
Attachment(s)	5 🗖 Nation of lef	December 1 December 1 April 1 and 1	
 Notice of References Cited (PTO-892) D Notice of Draftperson's Patent Drawing Review (PT 		ormal Patent Application (PTO-152)	
	Paper No./I	mmary (PTO-413), ⁄lail Date	
 Information Disclosure Statements (PTO-1449 or P Paper No./Mail Date 	<u> </u>	Amendment/Comment	
4. Examiner's Comment Regarding Requirement for D		Statement of Reasons for Allowance	
of Biological Material		VAL WANTENEAD, JB. ISORY PATENT EXAMINER NOLOGY CENTER 2800	

DETAILED ACTION

Allowable Subject Matter

- 1. Claims 1-20 are allowed.
- 2. The following is an examiner's statement of reasons for allowance:

The primary reason for allowance is the inclusion of a step of feeding a single fluorine compound gas having a reducing function into a via-hole that is to be filled with tungsten (W). The prior art of record (see, for example, U.S. Patent No. 6,066,366 to Berenbaum et al.; U.S. Patent Publication No. 2003/0003707 to Yamaha) generally teaches a two-step tungsten deposition process, including flowing WF₆ and silane together to form a tungsten nucleus, and then flowing WF₆ and hydrogen together to deposit the tungsten plug. There is no suggestion in the prior art, however, of flowing a single fluorine compound reduction gas into the via-hole, rather than flowing a combination of reduction gases, such as WF₆ and silane, into the via-hole.

Since performing a step of flowing a single fluorine compound reducing gas, such as WF_6 prior to the nucleation step (i.e., flowing WF_6 + silane) has the unexpected advantage of removing residual oxides from the interior of the viahole, thus leading to lower wiring resistance and greater reliability, and since there is simply no motivation in the prior art to flow the fluorine compound gas (such as WF_6) alone, before performing the tungsten nucleation and deposition steps (i.e., flowing WF_6 in combination with other reducing gases), it is the examiner's opinion that the method as claimed would not have been obvious to a person having ordinary skill in the art.

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Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for

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Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jennifer M. Dolan whose telephone number is (571) 272-1690. The examiner can normally be reached on Monday-Friday 8:30am-5:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl W. Whitehead, Jr. can be reached on (571) 272-1702. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jennifer M. Dolan Examiner Art Unit 2813

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